IN THE SPECIFICATION:

Please delete the title "ACIDIC POLISHING SLURRY FOR THE CHEMICAL-MECHANICAL POLISHING OF SIO₂ ISOLATION LAYERS" on page 1 of the application and on the abstract and replace with the following:

--METHOD FOR POLISHING A COMPOSITE MATERIAL CONTAINING SILICA AND SILICON NITRIDE WITH AN ACIDIC POLISHING SLURRY--.

A new Abstract Page is enclosed.